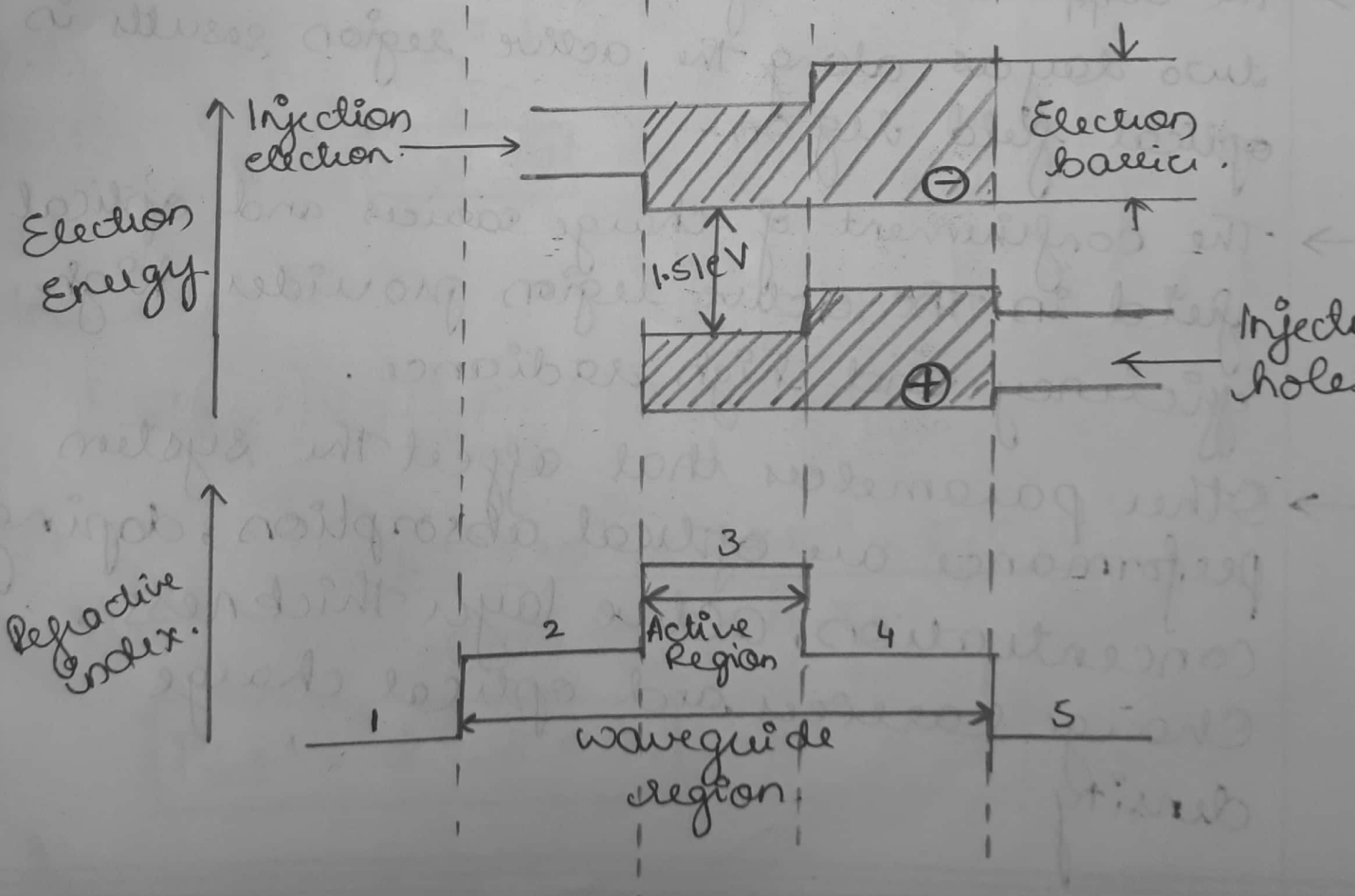


Internal Assessment Test II - April 2019.

1. Draw the cross section of GaAlAs double hetero structure light emitter energy band gap diagram and refractive index variation. Explain the importance.

Metal contact	n-type GaAs 1μm carrier layer	n-type Ga _{1-x} Al _x As 1μm confining layer	n-type Ga _{1-y} Al _y As 0.3μm Recombination layer	p-type Ga _{1-x} Al _x As 1μm carrier layer	p-type GaAs 1μm metal improvement layer	Metal contact
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- Double hetero structure is due to the different alloy layers along the active region.
- GaAlAs structure came into study based on the studies of laser diodes.
- Since two alloy layers are along the active region it confines of the charge carriers and optical field region.
- The difference in energy gap between the two layers along the active region results in charge carriers.
- The difference in refractive index between the two layers along the active region results in optical field region.
- The confinement of charge carriers and optical field in the active region provides high efficiency and high radiance.
- Other parameters that affect the system performance are optical absorption, doping concentration, active layer thickness, charge carriers and optical charge density.

5.

Recombination bulk time

$$\tau = \frac{\tau_r \tau_{nr}}{\tau_r + \tau_{nr}}$$

$$= \frac{30 \times 100}{30 + 100}$$

$$= 27.1 \text{ ns}$$

Internal quantum efficiency

$$\eta_{int} = \frac{\tau}{\tau_r}$$

$$= \frac{27.1}{30}$$

$$= 0.903$$

Internal Power

$$P_{int} = \frac{hcI}{\lambda \eta_{int}}$$

$$= \frac{6.625 \times 10^{-34} \times 3 \times 10^8 \times 0.040}{1310 \times 10^{-9} \times 0.903}$$

$$= 29.2 \text{ mW}$$

$$P_{int} = 29.2 \text{ mW}$$

6. Derive the expression for lasing condition and hence for optical gain in laser.

To determine lasing condition and resonant frequency we express electric field as electric phasor vector

$$E(z, t) = I(z) e^{-j(\omega t - \beta z)}$$

where $I(z) \rightarrow$ Optical Field Intensity

$\omega \rightarrow$ Optical Radian Frequency

$\beta \rightarrow$ Propagation constant.

Lasing is a condition when light amplification is possible in the diode. The requirement for lasing is that population inversion should take place.

$$I(z) = I(0) \exp \{ [\Gamma g(\hbar\nu) - \bar{\alpha}(\hbar\nu)] z \}$$

where $\bar{\alpha} \rightarrow$ effective absorption coefficient
 $\Gamma \rightarrow$ optical fibre confinement factor.

When two materials with different refractive indices are used,

$$R = \left(\frac{n_1 - n_2}{n_1 + n_2} \right)^2.$$

Replace $z = 2L$

$$I(2L) = I(0) R_1 R_2 \exp \left\{ \left[\Gamma g(n_2) - \bar{\alpha} (n_2) 2L \right] \right\}$$

$$I(2L) = I(0)$$

$$e^{-j\omega\beta L} = 1.$$

$$g_{th} = \bar{\alpha} = \alpha_{end} + \frac{1}{2L} \ln \left(\frac{1}{R_1 R_2} \right)$$

$$= \alpha_{end} + \alpha_t.$$

Lasing occurs when

$$g \geq g_{th}.$$

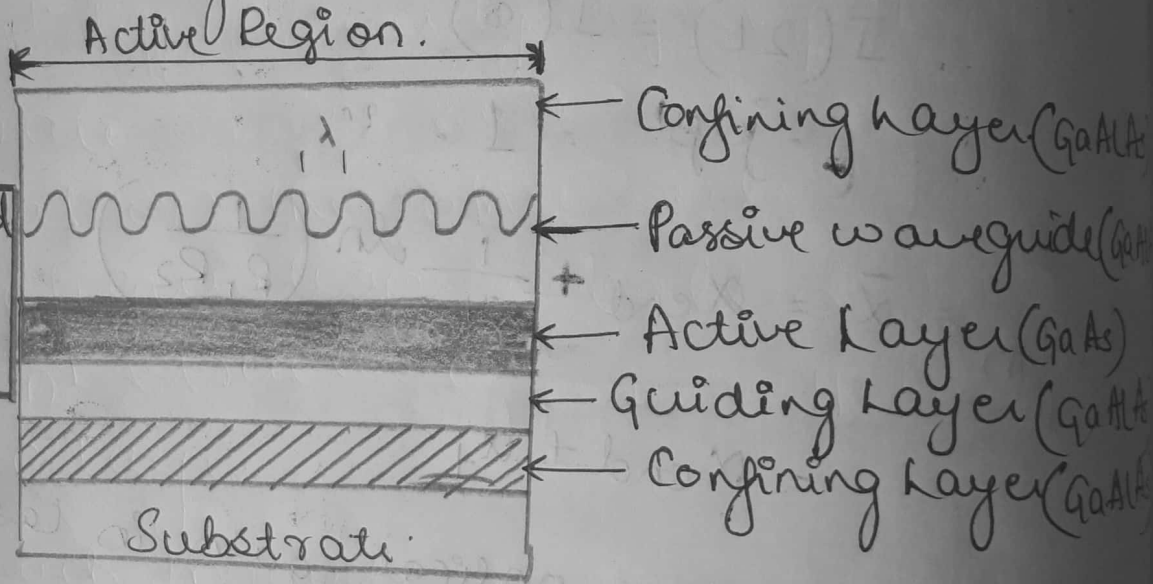
when $g_{th} \rightarrow$ optical gain is laser.

7b. Types of laser with schematic diagram of any two laser types.

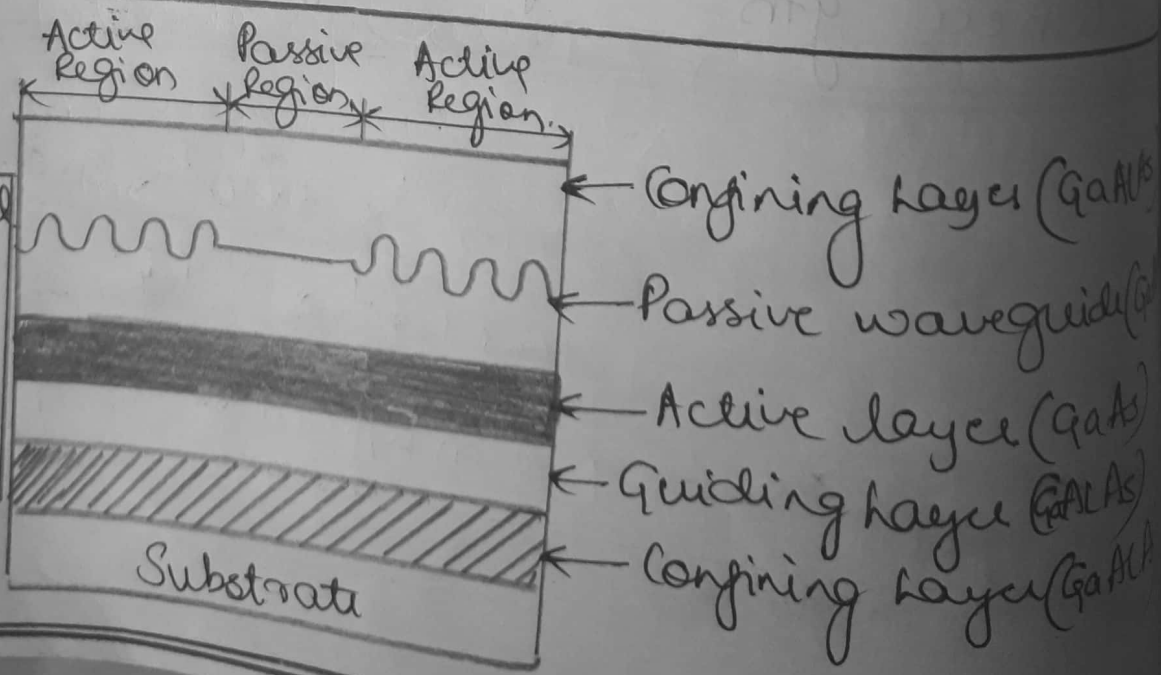
Types of LASER are.

- Distributed feedback Laser
- Distributed Bragg reflector Laser.
- Distributed Reflector Laser.

Distributed Feedback Laser.

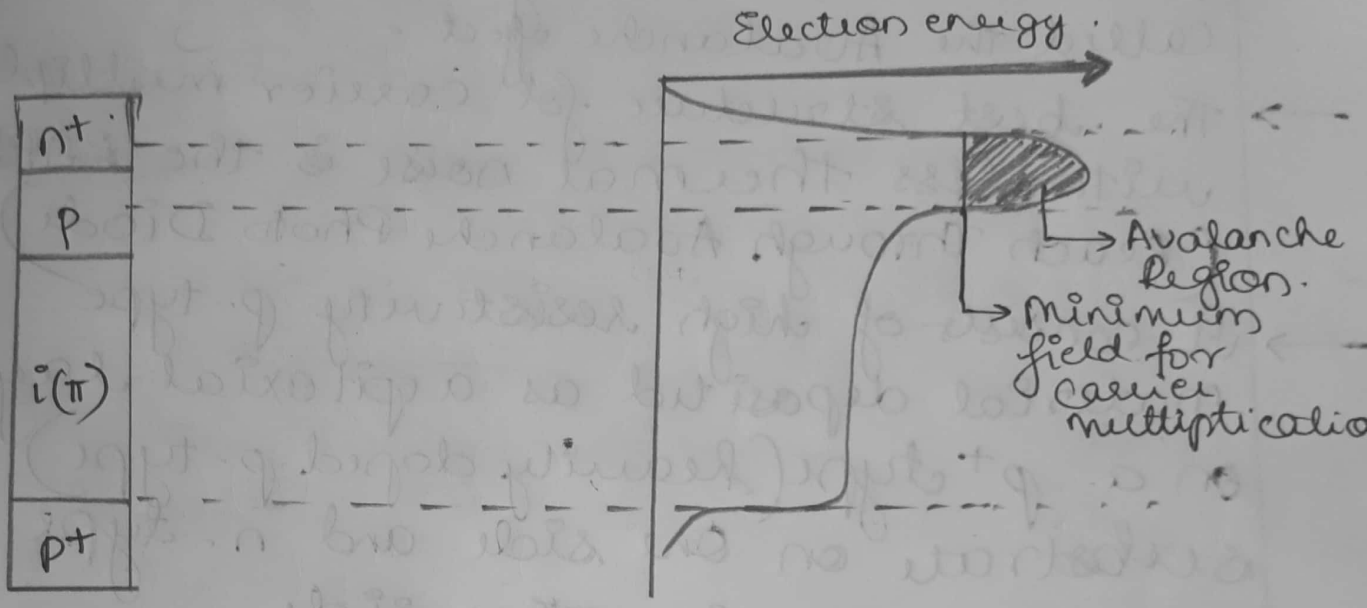


Distributed Bragg Reflector Laser



3b)

With Proper sketch explain RAPD photodiode



- Avalanche photodiode internally multiply primary single photocurrent before the signal could enter the input of the following amplifier.
- This increases the receive sensitivity, as the photocurrent is multiplied before it is mixed with the thermal noise of the receive circuit.
- In order for carrier multiplication to take place the charge carriers should pass through a high energy electric field where the carrier gains energy and move the bound electrons from valence band by colliding with them.
- This condition is known as Ionization Impact of the charge carriers.
- Before the diode breakdown voltage, there are finite number of charge carriers and

infinite number of charge carriers after the breakdown voltage. This phenomenon is called the Avalanche effect.

→ The best structure for carrier multiplication with less thermal noise is the RAPD (Reach Through Avalanche Photo Diode).

→ It consists of high resistivity p-type material deposited as an epitaxial layer on a p^+ type (heavily doped p-type) substrate on one side and n-type material on the other side.

→ This configuration is called the $p^+ \pi p^+$ structure where π is the intrinsic layer.

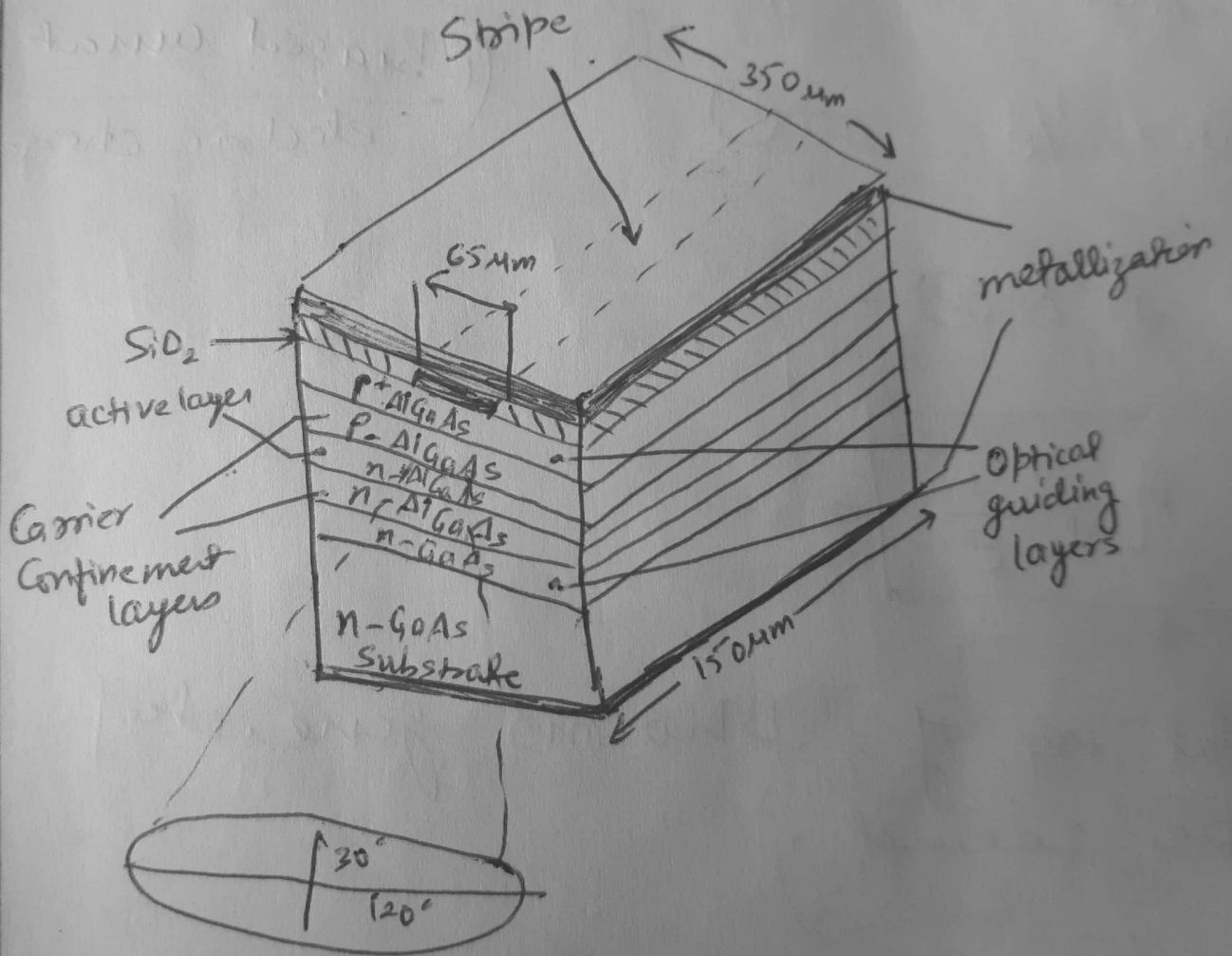
→ The 'reach-through' term is based on the photodiode operation where the depletion region increases and reaches through the semiconductor region.

3) a) Intermodal Dispersion :

- Pulse broadening in fibres results from the propagation delay between different modes.
- The output of the fibre depends on the transmission times of slowest and fastest modes.
- In single step fibre, there is no intermodal dispersion.
- Intermodal dispersion can be reduced by adopting optimal refractive index.
- In multimode step index fibre, there is large propagation delay. It has large intermodal dispersion.
- In single step fibres, only intramodal dispersion occurs.
- The pulse broadening mainly depends on the delays that occur within an optical fibre cable.

4.

Edge Emitter LED



7(a)

Optical fiber Connector-

1. Low coupling losses
2. Interchangeability
3. Ease of assembly
4. Low environmental sensitivity
5. Low cost and reliability
6. Ease of connection